IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

Applicant: Alan F. Jankowski et al Docket No.

IL-10991

Customer No: 24981

Serial No.

Art Unit

Filed

Examiner

For

Vapor-Deposited Porous Films for Energy

Conversion

INFORMATION DISCLOSURE STATEMENT

Commissioner for Patents Alexandria, VA 22313-1450

Dear Sir:

Forwarded herewith is an Information Disclosure Statement, Form-1449, in the above-identified application. Copy of the cited reference is enclosed.

Respectfully submitted,

Ann M. Lee

Agent for Applicants Registration No. 47,741

Dated:

Enclosure:

As noted above

(+) inside this box + PTO/SB/08B (08-00)

Approved for use through 10/31/2002. OMB 0651-0031

U.S. Patent and Trademark Office: U.S. DEPARTMENT OF COMMERCE

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Substitute for			Application Number											
		ATION DISCLOSURE	Filing Date First Named Inventor				•	$\neg \neg$						
STA	TEM	ENT BY APPLICANT				Alan Jankowski et al								
		e as many sheets as necessary)		Group Art Unit										
				Examiner Name										
Sheet of Attorney Docket Number IL-11019														
	OTHER PRIOR ART - NON PATENT LITERATURE DOCUMENTS													
Examiner Initials*	Cite No.1													
·		T. Tsai et al	Sputter deposition of cermet fuel electrodes for solid oxide			ļ	J. Vac. Sci, Technol. A 13 (3) May/June 1995							
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^{*}EXAMINER: Initial if reference considered, whether or not citation is in conformance with MPEP 609. Draw line through citation if not in conformance and not considered. Include copy of this form with next communication to applicant.

¹ Unique citation designation number. ² Applicant is to place a check mark here if English language Translation is attached. SEND TO: Commissioner for Patents, Washington, DC 20231